

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Kazunari KURITA et al.

Art Unit: not yet assigned

Application No.: not yet assigned

Examiner: not yet assigned

Filed: 04/19/2006

Attorney Dkt. No.: 12054-0059

For: PROCESS FOR PRODUCING HIGH-RESISTANCE SILICON WAFERS AND
PROCESS FOR PRODUCING EPITAXIAL WAFERS AND SOI WAFERS (AS
AMENDED)

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Prior to examination on the merits of the above-identified application, please
amend the application as set forth below.

Amendments to the specification are submitted on page 2.

Amendments to the claims are submitted on page 3.

Remarks are submitted on page 5.